ETCHING CARTRIDGE



All stainless steel filtration filter using precision etching processing

Advanced etching technology

Using photo etching technology used in the field of electronic parts manufacturing for semiconductors etc, accurate hole is uniformly opened, so filtration accuracy is maintained.

The risk of contamination is drastically reduced

There is no breakage of the steel wire due to breakage as compared to the wire mesh strainer, and there are few residues due to clogging.

Excellent Regenerative cleaning

Because the structure is simple, it is excellent in regeneration cleaning and sanitary properties. It is economical because it can be washed and reused.

Chemical resistance

Alkaline and acid type chemicals are available.

Filter composition

Media: SUS316L End Plate: SCS14

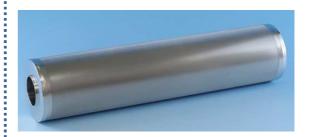
Filtration accuracy (Equivalent to mesh)

20#, 40#, 60#, 80#, 100#, 120#, 150#, 200#

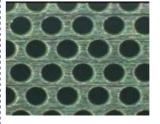
Filtration area

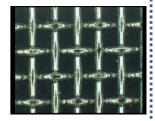
Nominal Length (in)	10	20	30
Filtration area (m²)	0.04	0.09	0.13





Cylindrical cartridge



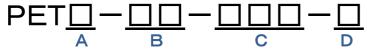


Etching

Wire mesh

Model

Please select a model within the frame



Mounting structure

No mark: Flat gasket type

W: 2220-ring type F: 2260-ring type

B Length (mm) (Excluding gaskets) 01: 241.5 02: 489 03: 733 *W • F type: 736.5 Grade
(Equivalent to mesh)

20# : 20mesh | 100# : 100mesh |
40# : 40mesh | 120# : 120mesh |
60# : 60mesh | 150# : 150mesh |
80# : 80mesh | 200# : 200mesh

Gasket Materials

N: NBR

T: PTFE

D: Silicon

V: Fluororubber

E: EPDM

Mounting structure

H type (Flat gasket type)

W type (2220-ring type)

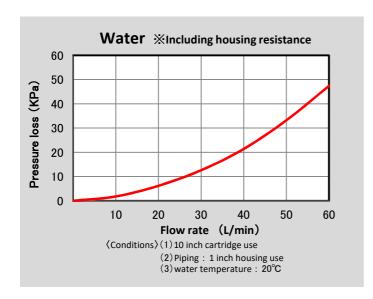
F type (2260-ring type)

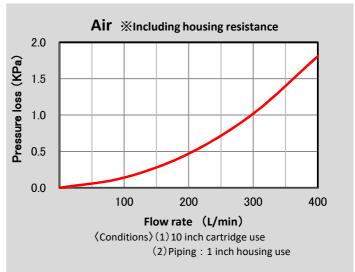






Flow characteristic





Method for cleaning and recycling cartridge

Backwashing

Degrease the filter

(Refer to solvent degreasing, alkaline degreasing, surface activated degreasing.)

- ■With a soft brush, carefully brush the surface to remove dirt.
- ■Blow compressed air from the inside of the cartridge. (Repeat above several times)
- Degrease with a clean degreasing agent.
- ■Use compressed air to blow water, wash thoroughly, dry and finish it.

- Ochemical cleaning Off backwashing can not be completed, wash with mixed acid and treat with nitric acid.
 - ■Wash thoroughly with water, blow compressed air to remove moisture and dry.

- Ultrasonic cleaning Perform ultrasonic cleaning in the cleaning solution.
 - Wash thoroughly and dry.

To achieve desirable cleaning result recommended combine all above cleaning method.

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